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I HEREBY CERTIFY THAT THIS CORRESPONDENCE IS BEING
TRANSMITTED VIA FACSIMILE TO THE COMMISSIONER FOR
PATENTS, WASHINGTON, D.C. 20231, ON

Date of Deposit: May 28, 2002
Name of Person Making Deposit: Colleen Dew

Signature: *Colleen J. Dew*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of: M. Khare <i>et al.</i>	May 28, 2002
	Examiner: Fernando L. Toledo
Serial No. 09/809,663 Filing Date: March 15, 2001	Group Art Unit: 2823
Title: METHOD FOR IMPROVED PLASMA NITRIDATION OF ULTRA THIN GATE DIELECTRICS	IBM Corporation 2070 Route 52 Dept. 18G, Bldg. 300-482 Hopewell Junction, N.Y. 12533

AMENDMENT UNDER 37 C.F.R. § 1.111

The Commissioner for Patents
Washington, D.C. 20231

FAX COPY RECEIVED

MAY 28 2002

Sir:

TECHNOLOGY CENTER 2800

In response to the non-final Office Action mailed February 28, 2002, Applicants respectfully request entry of the following amendments and remarks into the file of the above-identified application.

In the claims:

Cancel Claims 4, 5 and 9-13, without prejudice.

FIS9-2000-0396-US1

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S/N 09/809,663